

PATENT ASSIGNMENT COVER SHEET

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SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	ASSIGNMENT
CONVEYING PARTY DATA	
Name	Execution Date
NEC CORPORATION	01/19/2016
RECEIVING PARTY DATA	
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PROPERTY NUMBERS Total: 1	
Property Type	Number
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DATE SIGNED:	02/29/2016
Total Attachments: 2	
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ASSIGNMENT

For good and valuable consideration, the receipt and sufficiency of which are hereby acknowledged, the undersigned:

NEC CORPORATION

having an address at

7-1, Shiba 5-chome, Minato-ku
Tokyo, 108-0014 Japan

(hereinafter ASSIGNOR) co-owner of the rights in the United States of America and its territories and possessions to the below listed U.S. Patent, as evidenced in the records in the U.S. Patent and Trademark Office, hereby sells and assigns, unto:

SCIOCS COMPANY LIMITED

having an address at

880 Isagozawa-cho, Hitachi-shi
Ibaraki-ken, 319-1418 Japan

(hereinafter ASSIGNEE) all of ASSIGNOR'S right, title and interest for the United States of America, its territories and possessions, in and to the invention and the patent therefor, identified as follows:

<u>PATENT NUMBER</u>	<u>ISSUE DATE</u>	<u>TITLE</u>
6,824,610	November 30, 2004	PROCESS FOR PRODUCING GALLIUM NITRIDE CRYSTAL SUBSTRATE, AND GALLIUM NITRIDE CRYSTAL SUBSTRATE

including all reissue and extensions of said Letters Patent.

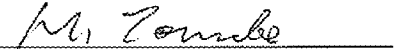
The undersigned hereby grants the firm of FOLEY & LARDNER LLP the power to insert in this Assignment any further identification which may be necessary or desirable to comply with the rules of the U.S. Patent and Trademark Office for recordation of this Assignment.

Company: NEC CORPORATION

Date: 19 JAN 2016

By: 
Name: Shigeki Wada
Title: Department Manager
Development Promotion Department

Date: 19 JAN 2016
Date: 19 JAN 2016

WITNESS: 
WITNESS: 